

The CDF® System comprises a series of presensitized, direct system photographic stencil films suited to a broad range of inks and printing applications.

## **Capillary Films**

## **Manufacturers' Cross Reference**

Mild Solvent Resistant, <i>Diazo</i>	Autotype	Chromaline	Kiwo	Fotec	Saati	Murakami
CDF®The original, diazo-sensitized film intended for use with relatively mild solvent-based inks such as enamels, poster inks, or plastisols. Not to be used with water-based inks or inks containing vinyl solvents.  Available in 15, 20, 30, 38, 50 and 70m thicknesses	Capillex 18, 25, 35, 50, 80	Pro/Cap	Kiwo Film DS	Fotecap Topaz		

Solvent-Resistant, <i>Dual-Cure</i>					
CDF®/Matrix An easy to apply diazo-photopolymer dual-cure film featuring exceptional imaging properties and total solvent resistance. Intended for use with all solvent-based inks.  CDF/Matrix-UV, Matrix-20, Matrix-30, and Matrix-40.	Capillex 20, CP, CX	Magna/ Cure	Fotecap CD Fotecap Saphir	DCF	

Solvent Resistant, <i>Photopolymer</i>				
<ul><li>CDF®/QSR A fast exposing SBQ/Diazo sensitized film intended for use with all solvent-based inks.</li><li>Available in 10, 15, 20, 30 and 40m thicknesses.</li></ul>	Capillex 30		Fotecap Zircon	MS Film MS/WS MS Graphic Film

## Textile, Pure Photopolymer CDF®/QT SBQ (pure photopolymer) films are resistant to plastisol inks. While 30 and 50m films are appropriate for halftone work and general sportswear printing, **Phat** respectively, the thicker films should be used for high-Film density textile printing or other applications, such as MS peelable solder mask, requiring thick ink deposits **Fotecap** Thik Thick through coarse mesh. Mild ink wash-up solvents, such **Super** Tecno Film Film as Ulano's All Purpose Ink Wash or mineral spirits, Phat should be used with all CDF"/QT films. Avoid screen openers and aggressive solvents to allow for easy Available in 30, 50, 100, 150, 200, 250, 300, 400 and 700m thicknesses.